Special Issue

Advances in Sol-Gel Processes

Message from the Guest Editors

This Special Issue is part of the development of materials with controlled morphology and texture synthesized by the sol-gel process. The developed methodology in this Special Issue should integrate aspects related to the microstructure of the material, characterization of the end-use properties of the final material, and design of the manufacturing process from the laboratory to the industrial scale. This objective requires combining synthesis work, characterization work, and modeling work.

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